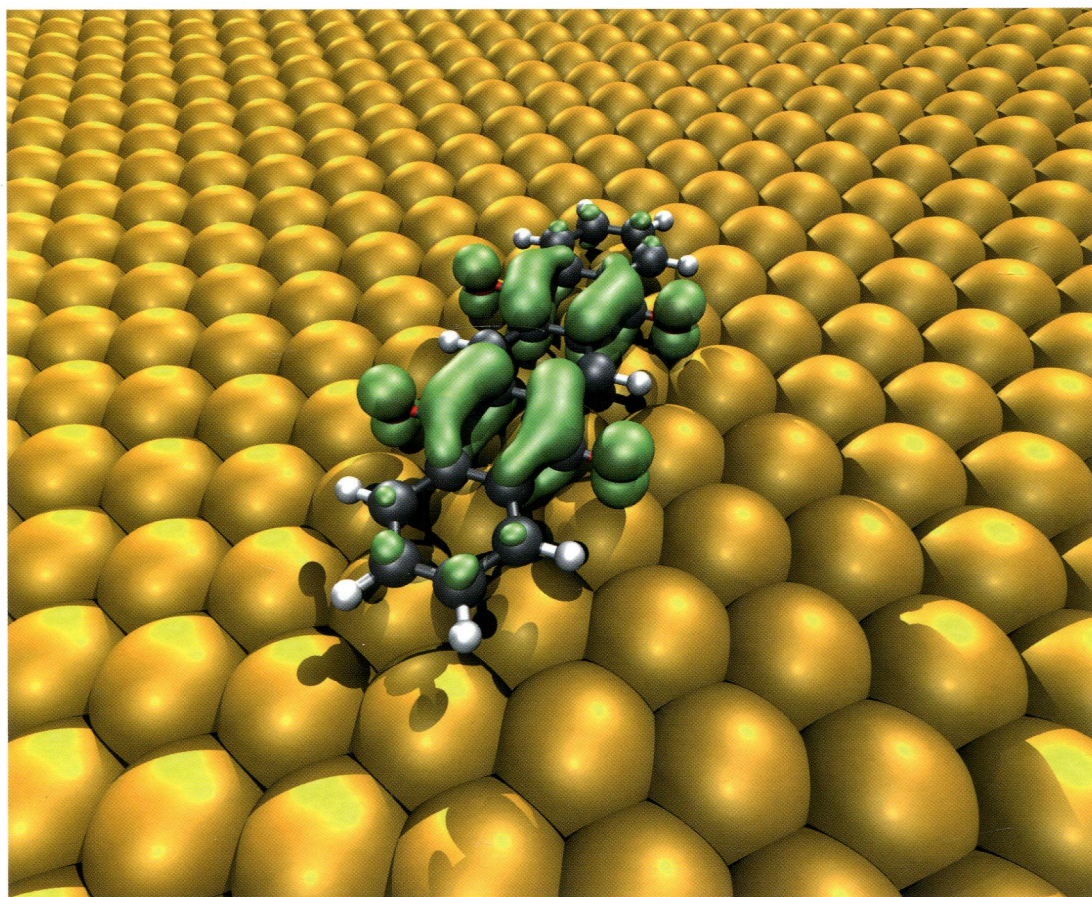


Edited by
N. Koch, N. Ueno, and A.T.S. Wee

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The Molecule-Metal Interface



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Cover Picture

Lowest unoccupied molecular orbital of 5,7,12,14-pentacenetetrone on the Au(111) surface as calculated by density-functional theory. The illustration was created with VMD. VMD was developed by the Theoretical and Computational Biophysics Group in the Beckman Institute for Advanced Science and Technology at the University of Illinois at Urbana-Champaign. Courtesy of G. Heimel.

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Library of Congress Card No.:
applied for

British Library Cataloguing-in-Publication Data:
A catalogue record for this book is available from the British Library.

Bibliographic information published by the Deutsche Nationalbibliothek
The Deutsche Nationalbibliothek lists this publication in the Deutsche Nationalbibliografie; detailed bibliographic data are available on the Internet at <http://dnb.d-nb.de>.

© 2013 WILEY-VCH Verlag GmbH & Co. KGaA, Boschstr. 12, 69469 Weinheim, Germany

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Composition le-tex publishing services GmbH, Leipzig

Printing and Binding Markono Print Media Pte Ltd, Singapore

Cover Design Grafik-Design Schulz, Fußgönheim

Print ISBN 978-3-527-41060-6

ePDF ISBN 978-3-527-65320-1

ePub ISBN 978-3-527-65319-5

mobi ISBN 978-3-527-65318-8

oBook ISBN 978-3-527-65317-1

Printed in Singapore

Printed on acid-free paper

Contents

Preface XI

List of Contributors XIII

1 Introduction to the Molecule–Metal Interface 1

Nobuo Ueno, Norbert Koch, and Andrew T.S. Wee

- 1.1 From Organic Semiconductors to Organic Electronic Devices 1
- 1.2 Role and Function of Interfaces in Organic Electronic Devices 3
- 1.3 What Will We Learn about the Interfaces? 4
- 1.4 The Fermi Level and Related Fundamentals 6
 - 1.4.1 Definition of the Fermi Level in this Book 6
 - 1.4.2 Measuring the Fermi Level of Organic Semiconductors 8
 - 1.4.3 The Work Function and the Vacuum Level of a Solid with Finite Size 9
- References 13

Part One Theory 15

2 Basic Theory of the Molecule–Metal Interface 17

Fernando Flores and José Ortega

- 2.1 Introduction 17
- 2.2 The Molecule Energy Gap Problem: Image Potential Effects 20
 - 2.2.1 Molecule Self-Interaction Energy 20
 - 2.2.2 Image Potential Effects 25
- 2.3 The Unified IDIS Model: Charge Transfer, Pauli Exclusion Principle (“Pillow”) Effect and Molecular Dipoles 28
 - 2.3.1 The IDIS Model 28
 - 2.3.2 Pauli Repulsion (“Pillow”) Effect and the Unified IDIS-Model 31
 - 2.3.3 Molecular Dipole Corrections and the Unified IDIS Model 34
- 2.4 DFT Calculations for a Single Molecule on a Surface 35
 - 2.4.1 C60 on Au(111) 35
 - 2.4.2 TCNQ/Au(111) 38
 - 2.4.3 TTF on Au(111) 39
- 2.5 From a Single Molecule to a Monolayer 42
 - 2.5.1 The Unified IDIS Model for an Organic Ad-layer on a Metal 42
 - 2.5.2 C60/Au(111) 43

2.5.3	TTF/Au(111)	45
2.5.4	More on the Unified IDIS Model	46
	References	48
3	Understanding the Metal–Molecule Interface from First Principles	51
	<i>Leeor Kronik and Yoshitada Morikawa</i>	
3.1	Introduction	51
3.2	A Brief Overview of Density Functional Theory	53
3.3	Electronic Structure of Metal–Molecule Interfaces from Density Functional Theory: Challenges and Progress	59
3.4	Understanding Metal–Molecule Interface Dipoles from First Principles	64
3.4.1	<i>n</i> -Alkane/Metal Interfaces	67
3.4.2	Benzene/Metal Interfaces	68
3.4.3	Pentacene/Metal Interfaces	72
3.4.4	PTCDA/Metal Interfaces	75
3.5	Two Examples of Collective Effects at Metal–Molecule Interfaces	77
3.5.1	Quantum-Confined Stark Effect in Monolayers of Molecules Consisting of Polar Repeating Units	77
3.5.2	Magnetic Molecule/Magnetic Metal Interfaces	79
3.6	Concluding Remarks	81
	References	81
Part Two	Atomic Structure	91
4	STM Studies of Molecule–Metal Interfaces	93
	<i>Swee Liang Wong, Han Huang, Andrew T.S. Wee, and Wei Chen</i>	
4.1	Introduction to Scanning Tunneling Microscopy	94
4.1.1	Basic STM Operation	94
4.1.2	Theory of STM	96
4.1.3	Scanning Tunneling Spectroscopy	98
4.2	Factors Affecting Molecular Packing on Perfect Surfaces	100
4.2.1	Molecule–Substrate vs. Intermolecular Interactions	100
4.2.2	Commensurability with Substrate	103
4.2.3	Molecular Density Dependent Phase Transitions	104
4.3	Influence of Inhomogeneity at Metal Surfaces	106
4.3.1	Physical Inhomogeneity at Crystalline Interfaces	106
4.3.2	Surface Electronic States	108
4.3.3	Molecule-Induced Modification of Surface Topography	109
4.4	Manipulation of Molecules Using STM	112
4.5	Summary	116
	References	116
5	NEXAFS Studies of Molecular Orientations at Molecule–Substrate Interfaces	119
	<i>Dong-Chen Qi, Wei Chen, and Andrew T.S. Wee</i>	
5.1	Principles of NEXAFS	120

- 5.1.1 The X-Ray Absorption Process 120
- 5.1.2 Molecular Orbitals and Characteristic Resonances in *K*-shell NEXAFS Spectra 123
- 5.1.3 Molecular Orientation and Polarization Dependence of the Resonance Intensities 125
- 5.1.4 Techniques and Instrumentation of NEXAFS 127
- 5.1.5 Radiation Damage of NEXAFS 129
- 5.2 Molecular Orientations at Interfaces: the Effect of Molecule–Substrate Interactions 129
 - 5.2.1 Organic/Metal Interfaces 130
 - 5.2.2 Organic/Semiconductor Interfaces 132
 - 5.2.3 Organic/Organic Heterojunction Interfaces 136
 - 5.2.4 CuPc on Other Technologically Important Substrates 139
- 5.3 Molecular Orientations at Interfaces: the Effect of Strong Intermolecular Interactions 140
- 5.4 Molecular Orientations of Self-Assembled Monolayers 143
- 5.5 Summary and Outlook 147
- References 148

6 X-Ray Standing Waves and Surfaces X-Ray Scattering Studies of Molecule–Metal Interfaces 153

Alexander Gerlach, Christoph Bürker, Takuya Hosokai, and Frank Schreiber

- 6.1 Introduction 153
- 6.2 X-Ray Standing Wave Theory 154
 - 6.2.1 General Considerations on Wave Fields in Crystals 154
 - 6.2.2 The Two-Beam Approximation 155
 - 6.2.3 The Darwin Curve 156
 - 6.2.4 X-Ray Absorption and Dipole Approximation 159
 - 6.2.5 The Coherent Position and the Coherent Fraction 161
- 6.3 X-Ray Standing Wave Experiments 162
 - 6.3.1 Beamline Setup at ID32 162
 - 6.3.2 Experimental Details 163
- 6.4 Examples: Organic Monolayers on Metals 164
- References 170

Part Three Electronic Structure 173

7 Fundamental Electronic Structure of Organic Solids and Their Interfaces by Photoemission Spectroscopy and Related Methods 175

Nobuo Ueno, Satoshi Kera, and Kaname Kanai

- 7.1 Introduction 175
- 7.2 General View of Electronic Structure of Organic Solids 176
 - 7.2.1 From Single Molecule to Molecular Solid 176
 - 7.2.2 Contribution of Polaron 179
 - 7.2.3 Requirement from Thermodynamic Equilibrium 179
- 7.3 Electronic Structure in Relation to Charge Transport 180

- 7.3.1 Ultraviolet Photoemission Spectroscopy 180
 - 7.3.1.1 Energy and Momentum Conservation 180
 - 7.3.1.2 Energy Band Dispersion and Estimation of Band Transport Mobility 183
 - 7.3.1.3 Density of States Effects in Polycrystalline Films 184
- 7.3.2 Electron Spectroscopy Using Metastable Atom Beam: Characterization of the Molecular Orientation via Wavefunction Spread 186
 - 7.3.2.1 Principle and Characteristics 188
 - 7.3.2.2 Characterization of the Molecular Orientation 189
 - 7.3.2.3 Spatial Wavefunction Distribution of Band Gap States 190
- 7.3.3 Inverse Photoemission Spectroscopy (IPES) 191
 - 7.3.3.1 Characteristics of IPES 191
 - 7.3.3.2 Comparison between UPS-IPES and Tunneling Spectroscopy 195
 - 7.3.3.3 Comparison with Near-Edge X-Ray Absorption Fine Structure Spectroscopy (NEXAFS) 198
- 7.3.4 Probing Electron–Phonon Coupling, Hopping Mobility and Polaron by UPS 200
 - 7.3.4.1 Basic Background 200
 - 7.3.4.2 Experimental Reorganization Energy and Polaron Binding Energy 202
- 7.4 Electronic Structure at Weakly Interacting Interfaces 206
 - 7.4.1 Effects of Inhomogeneity of the Substrate Surface on the Energy Level Alignment 206
 - 7.4.2 Strange Band Bending 207
 - 7.4.3 Radiation Effects on the Energy Level Alignment 208
 - 7.4.4 Mysterious Phenomena: Fermi Level Alignment Issue 209
 - 7.4.4.1 Impacts of Interface Dipole Layer on the Energy Level Alignment 209
 - 7.4.4.2 Impacts of Disorder on the Energy Level Alignment and Band Bending 211
- 7.5 Summary 213
 - References 214

8 Energy Levels at Molecule–Metal Interfaces 219

Antoine Kahn and Norbert Koch

- 8.1 Introduction 219
- 8.2 The Organic–Electrode Interface 221
- 8.3 Gap States 223
- 8.4 Metal Electrodes 228
- 8.5 Tuning of Charge Injection Barriers 232
 - 8.5.1 Strong Electron Acceptor and Donor Molecules 234
 - 8.5.2 Self-Assembled Monolayers with Dipoles 236
- 8.6 Conductive Polymer Electrodes 237
 - References 238

9 Vibrational Spectroscopies for Future Studies of Molecule–Metal Interface 243

Wei-Yang Chou

- 9.1 Introduction 243

9.2	Selection Rules for Infrared and Raman Spectra	244
9.3	Raman/IR Application in Organic Films	245
	References	249
10	General Outlook	251
	<i>Norbert Koch, Nobuo Ueno, and Andrew T.S. Wee</i>	
	Index	253